

UNITED STATES PATENT AND TRADEMARK OFFICE
CERTIFICATE OF CORRECTION

PATENT NO. : 6,768,110 B2
DATED : July 27, 2004
INVENTOR(S) : Alani

Page 1 of 1

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

Column 13.

Line 58, "comprising providing a specimen having length and thick-" should read
-- comprising: providing a specimen having length and thick- --;

Column 14.

Line 7, "sion of said specimen, evacuating a chamber, position said" should read
-- sion of said specimen, evacuating a chamber, positioning said --;

Line 9, "specimen to provided an electron transparent surface of said" should read
-- specimen to provide an electron transparent surface of said --;

Line 28, "the progress of milling an said milling takes place." should read
-- the progress of milling as said milling takes place. --;

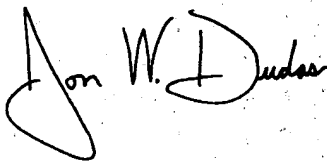
Column 15.

Line 11, "ion beam masking member much that there is no relative" should read
-- ion beam masking member such that there is no relative --; and

Line 20, "group consisting of circular square, rectangular, and ellip-" should read
-- group consisting of circular, square, rectangular, and ellip- --.

Signed and Sealed this

Twenty-seventh Day of December, 2005

A handwritten signature in black ink, reading "Jon W. Dudas", is enclosed within a rectangular box. The signature is written in a cursive, flowing style.

JON W. DUDAS

Director of the United States Patent and Trademark Office